



US00D754552S

(12) **United States Design Patent**
Chi

(10) **Patent No.:** **US D754,552 S**
(45) **Date of Patent:** **** Apr. 26, 2016**

(54) **SPIRIT LEVEL HAVING REFLECTION BUBBLE**

(71) Applicants: **HANGZHOU GREAT STAR TOOLS CO., LTD**, Hangzhou (CN);
HANGZHOU GREAT STAR INDUSTRIAL CO., LTD, Hangzhou (CN)

(72) Inventor: **Xiaoheng Chi**, Hangzhou (CN)

(73) Assignees: **Hangzhou Great Star Tools Co., LTD** (CN); **Hangzhou Great Star Industrial Co.** (CN)

(**) Term: **14 Years**

(21) Appl. No.: **29/513,025**

(22) Filed: **Dec. 24, 2014**

(30) **Foreign Application Priority Data**

Jun. 30, 2014 (CN) 2014 3 0212316

(51) **LOC (10) Cl.** **10-04**

(52) **U.S. Cl.**
USPC **D10/69**

(58) **Field of Classification Search**
USPC D10/69
CPC G01C 9/24; G01C 9/26; G01C 9/28;
G01C 9/30; G01C 9/32; G01C 9/34; G01C 9/36

See application file for complete search history.

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Primary Examiner — Antoine D Davis

(74) *Attorney, Agent, or Firm* — Workman Nydegger

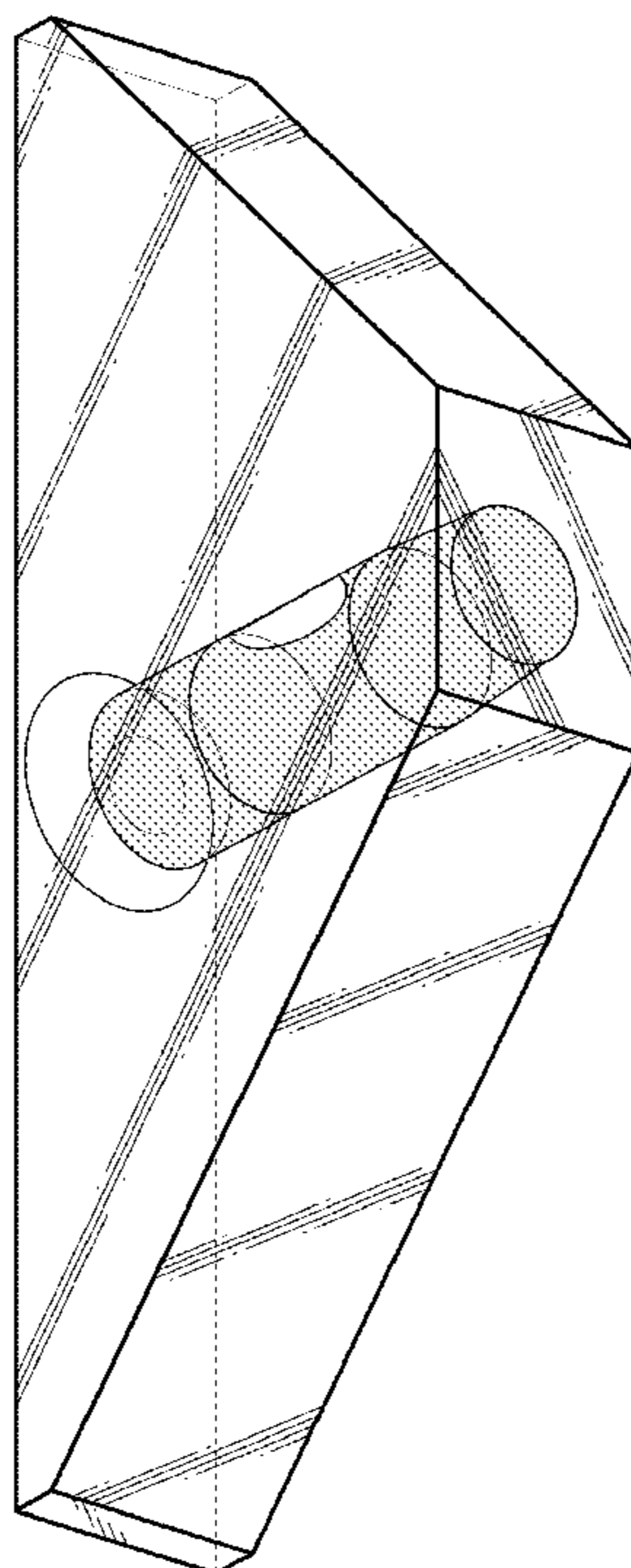
(57) **CLAIM**

The ornamental design of a spirit level having a reflection bubble, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of a first embodiment of a spirit level;
FIG. 2 is a front elevational view of the embodiment of FIG. 1;
FIG. 3 is a left elevational view of the embodiment of FIG. 1;
FIG. 4 is a right elevational view of the embodiment of FIG. 1;
FIG. 5 is a top elevational view of the embodiment of FIG. 1;
FIG. 6 is a bottom elevational view of the embodiment of FIG. 1; and,
FIG. 7 is a rear elevational view of the embodiment of FIG. 1.

1 Claim, 3 Drawing Sheets



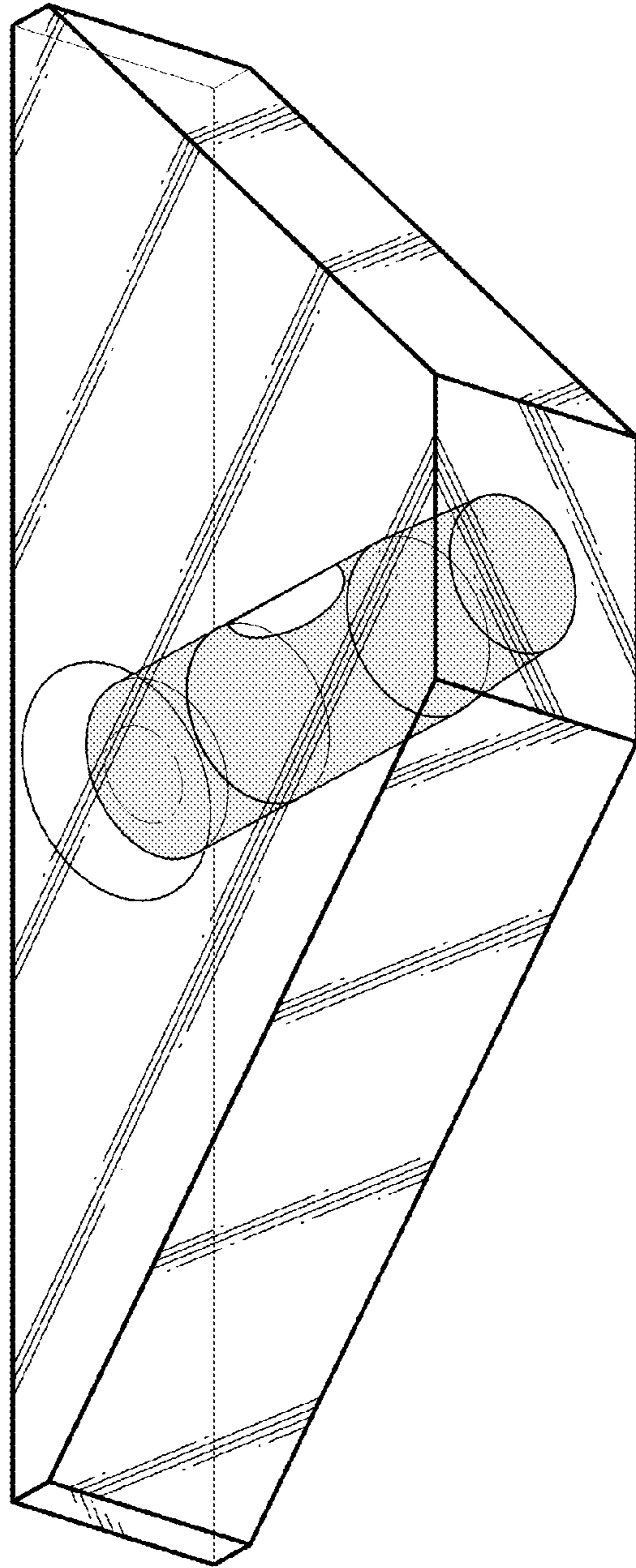


FIG. 1

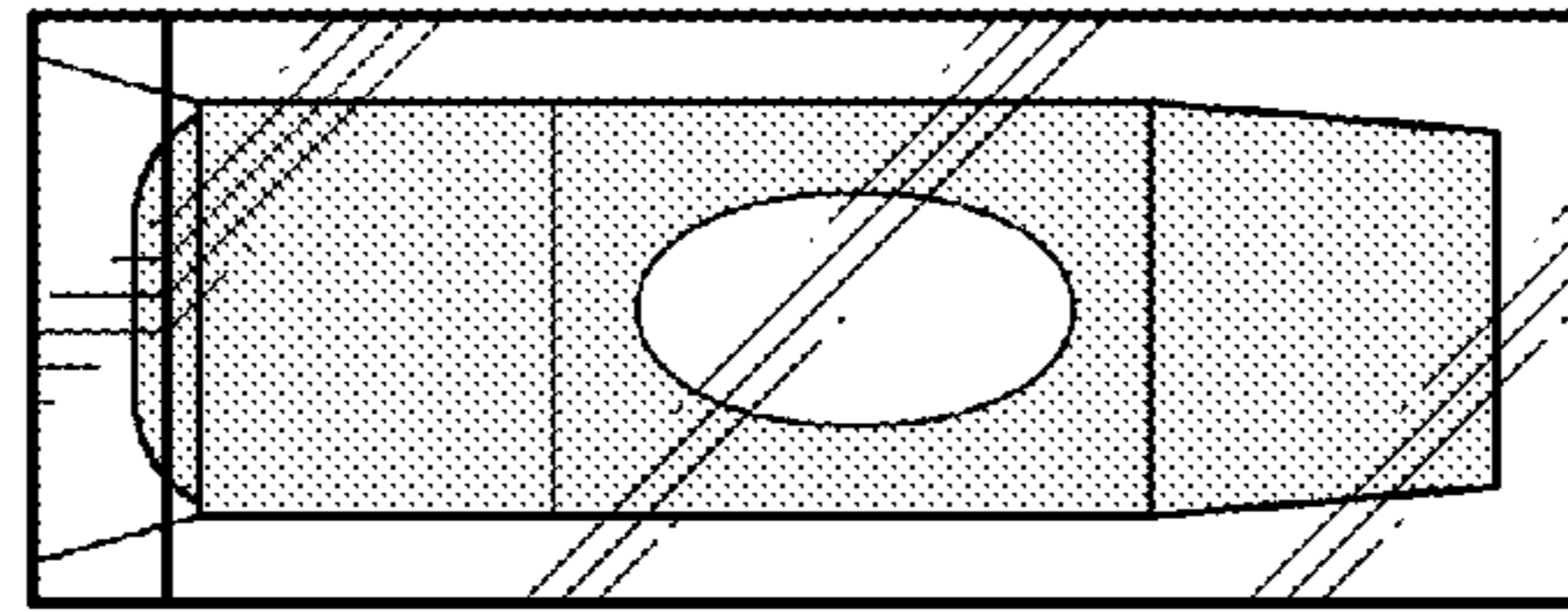


FIG. 5

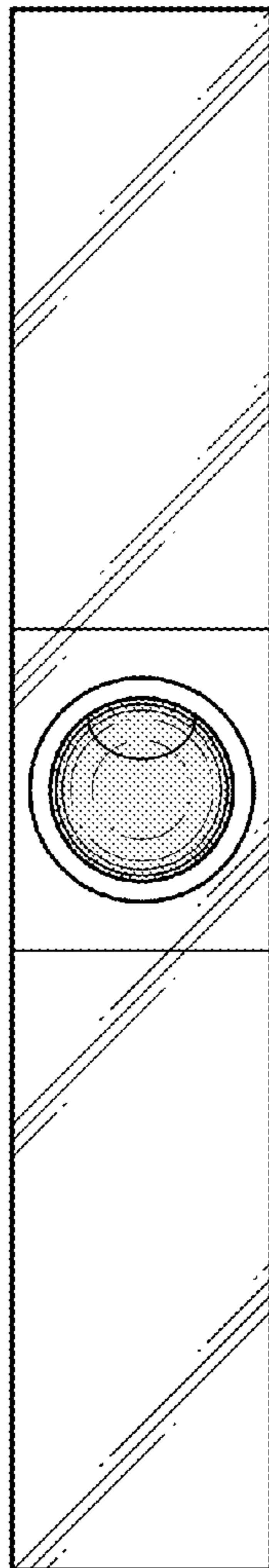


FIG. 3

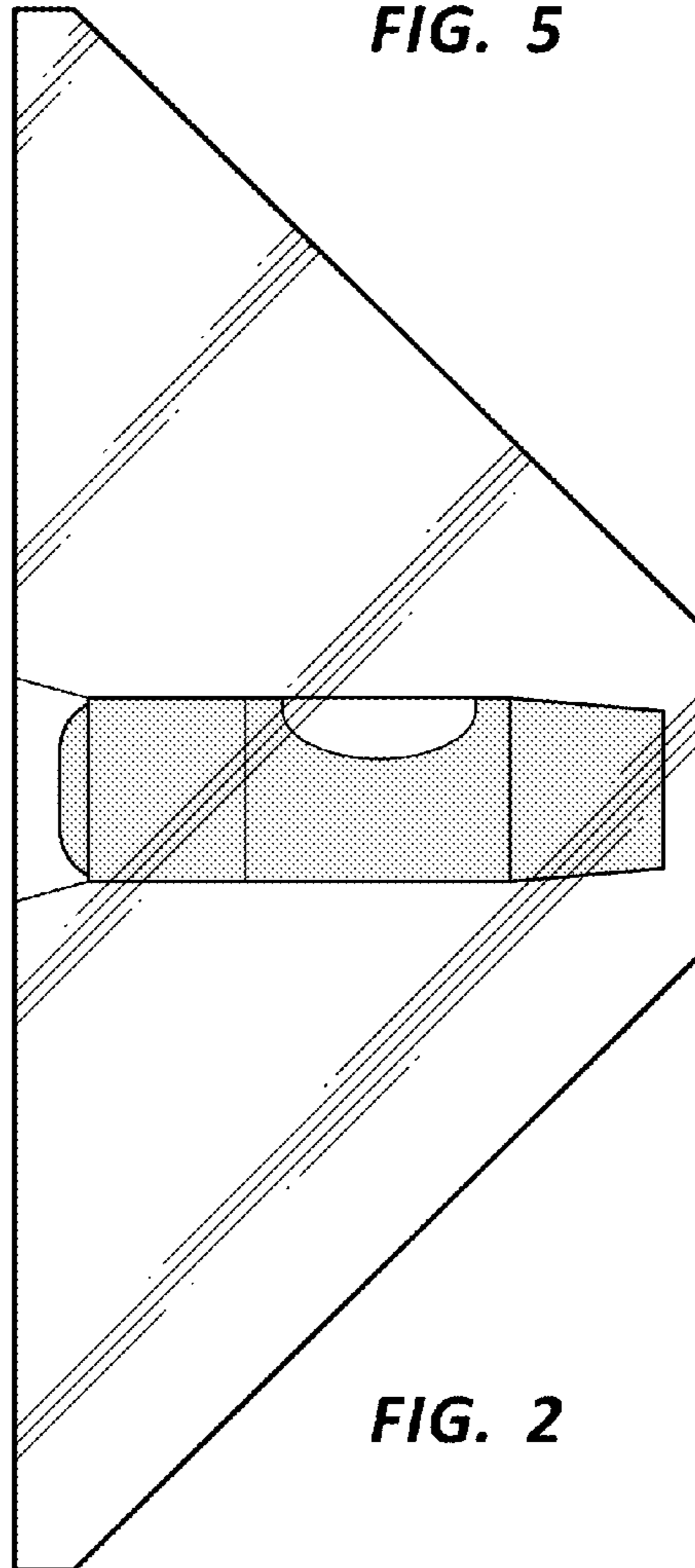


FIG. 2

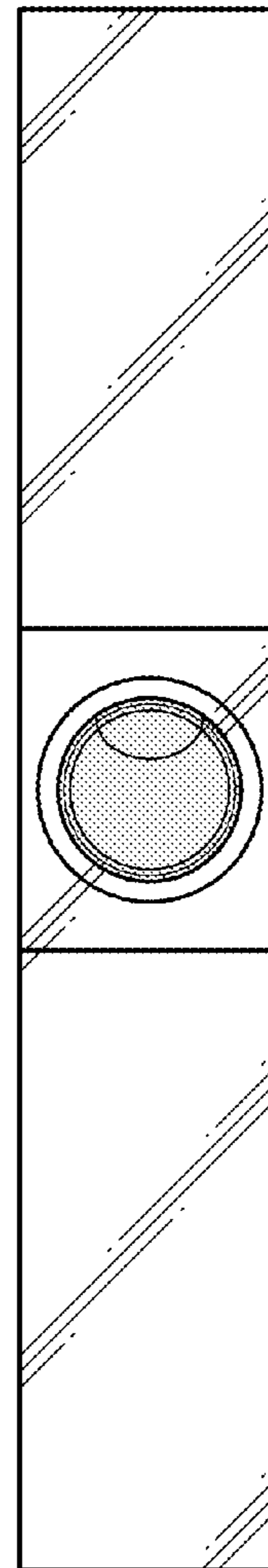


FIG. 4



FIG. 6

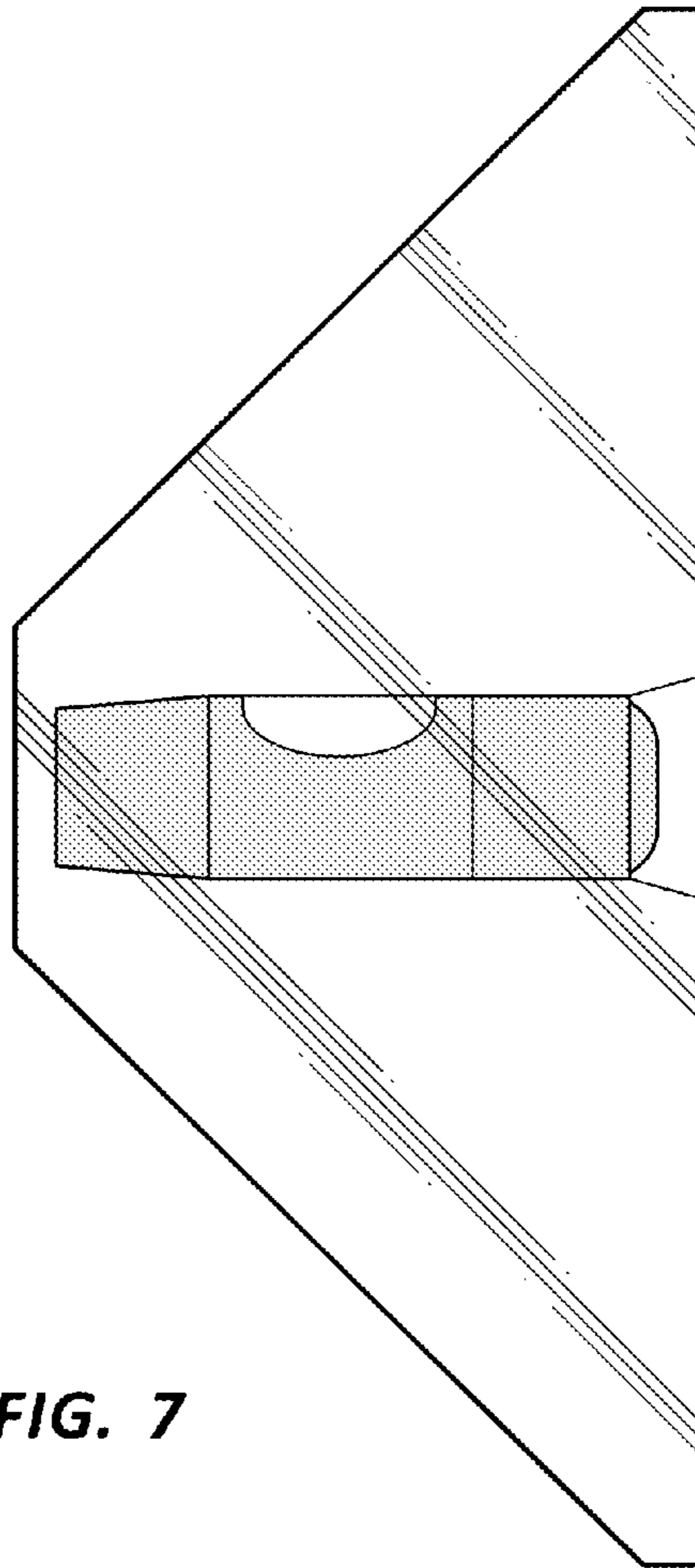


FIG. 7

UNITED STATES PATENT AND TRADEMARK OFFICE
CERTIFICATE OF CORRECTION

PATENT NO. : D754,552 S
APPLICATION NO. : 29/513025
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INVENTOR(S) : Xiaoheng Chi

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It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Title Page

Item 73, change "Hangzhou Great Star Industrial Co." to --Hangzhou Great Star Industrial Co., LTD--

Signed and Sealed this
Eighteenth Day of October, 2016



Michelle K. Lee
Director of the United States Patent and Trademark Office